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PATENT APPLICATION

Attorney Docket No.: 103512.99

AMENDMENT TRANSMITTAL

In re the Application of

Osamu TANITSU et al.

Group Art Unit: 2851

Application No.: 09/326,214

Examiner: A. Mathews

Filed: June 3, 1999

For: ILLUMINATION OPTICAL APPARATUS AND SCANNING EXPOSURE APPARATUS

Director of the U.S. Patent and Trademark Office
Washington, D.C. 20231

Sir:

Transmitted herewith is an Amendment in the above-identified application.

- ☐ Entitlement to small entity status is hereby asserted.
☐ Small entity status of this application has been established.

The filing fee has been calculated as shown below:

	(Column 1)	(Column 2)	(Column 3)
	CLAIMS REMAINING AFTER AMENDMENT	HIGHEST NO. PREVIOUSLY PAID FOR	PRESENT EXTRA
TOTAL CLAIMS	*104 MINUS	**104	=0
INDEP CLAIMS	*23 MINUS	***20	=3
<input type="checkbox"/> FIRST PRESENTATION OF MULTIPLE DEP. CLAIM			

SMALL ENTITY	
RATE	ADD'L FEE
x 9	\$
x 42	\$
+140	\$
	\$

OTHER THAN A SMALL ENTITY	
RATE	ADD'L FEE
x 18	\$
x 84	\$ 252
+280	\$
	\$ 252

- * If the entry in Column 1 is less than the entry in Column 2, write "0" in Column 3.
** If the "Highest Number Previously Paid For" IN THIS SPACE is less than 20, write "20" in this space.
*** If the "Highest Number Previously Paid For" IN THIS SPACE is less than 3, write "3" in this space.

The "Highest Number Previously Paid For" in this space (Total or Independent) is the highest number found from the equivalent box in Column 1 of a prior Amendment or the number of claims originally filed.

- ☒ Check No. 123763 in the amount of \$252.00 is attached. The Director is hereby authorized to charge any other fees that may be required to complete this filing, or to credit any overpayment, to Deposit Account No. 15-0461. Two duplicate copies of this sheet are attached.

DEPOSIT ACCOUNT USE
AUTHORIZATION
Please grant any extension
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Charge any fee due to our
Deposit Account No. 15-0461

Respectfully submitted,

James A. Oliff
Registration No. 27,075

Mario A. Costantino
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JAO:MAC/ccs

Date: October 11, 2001



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

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#12/B
10/22/01
APP
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AMENDMENT IN REISSUE APPLICATION

Director of the U.S. Patent and Trademark Office
Washington, D.C. 20231

10/16/2001 BSAYAS11 00000002 09326214

01 FC:109 Sir: 252.00 OP

In reply to the Office Action dated April 11, 2001, the shortened statutory period for reply being extended by the attached Petition for Extension of Time, please amend the above-identified application as follows:

IN THE CLAIMS:

10/12/2001 BSAYAS11 00000051 09326214

01 FC:102

252.00 OP

Please replace claims 77, 80 and 83-85 with the following amended claims:

77. (Amended) A device manufacturing method comprising a step of transferring a device pattern onto a work piece, wherein said transferring step comprises:
illuminating a rectangular area on a predetermined plane on which a mask is arranged with an illumination beam emerging from an internal reflection type integrator, an exit plane of said internal reflection type integrator having a shape substantially equal to a shape of said rectangular area; and
relatively moving said mask and said work piece with respect to said illumination beam, respectively, to perform scanning exposure of said work piece with said illumination beam through said mask.

Adjustment date: 10/16/2001 BSAYAS11
07/12/2001 BSAYAS11 00000051 09326214
1 FC:102

-252.00 OP